What is claimed is:

- 1. A method of preparing patterned colloidal crystals, the method comprising:
- filling a monomer solution into interstices of colloidal crystals for photopolymerization inside them; and performing a selective photopolymerization process in the interstices of colloidal crystals by use of a mask.
- 10 2. The method as defined in claim 1, wherein the monomer solution for the photopolymerization comprises an acrylate monomer.
- 3. The method as defined in claim 2, wherein the acrylate monomer is selected from the group consisting of hydroxypropyl methacrylate, hydroxyethyl methacrylate, methacrylate, or mixtures thereof.
- 4. The method as defined in claim 1, wherein the colloidal crystals each comprise at least one selected from the group consisting of polystyrene, polymethyl methacrylate, polyphenyl methacrylate, polyacrylate, polyalphamethylstyrene, poly1-methylcyclohexyl methacrylate, polycyclohexyl methacrylate, polycyclohexyl methacrylate, polycyclohexyl methacrylate, poly1-phenylcyclohexyl polychlorobenzyl methacrylate, poly1-phenylcyclohexyl

methacrylate, poly1-phenylethyl methacrylate, polyperfuryl poly1,2-diphenylethyl methacrylate, methacrylate, polypentabromophenyl methacrylate, polydiphenylmethyl methacrylate, polypentachlorophenyl methacrylate, copolymer of methyl methacrylate and benzyl methacrylate, copolymer of styrene and acrylonitrile, copolymer of methyl methacryalte and 2,2,2-trifluoroethyl methacrylate, copolymer of methyl methacryalte and 2,2,3,3,3-pentafluoropropyl methacrylate, methacryalte and copolymer οf methyl 1,1,1,3,3,3hexafluoroisomethacrylate, copolymer of methyl methacryalte and 2,2,3,3,4,4,4-heptafluorobutyl methacrylate, copolymer of 2,2,2-trifluoroethyl methacrylate and 2,2,3,3,3pentafluoropropyl methacrylate, copolymer of 2,2,2trifluoroethyl methacrylate and 1,1,1,3,3,3-15 hexafluoroisomethacrylate, copolymer of styrene and methyl 2,2,2-trifluoroethyl methacrylate, and copolymer of methacrylate and 2,2,3,3,4,4,4-heptafluorobutyl methacrylate.

- 5. The method as defined in claim 1, wherein the colloidal crystals each comprise at least one selected from the group consisting of SiO₂, TiO₂, ZnS, ZnO₂, and Fe₃O₄.
 - 6. The method as defined in claim 1, wherein light for use in the polymerization is selected between ultraviolet ranges and visible ranges.

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- 7. A method of preparing patterned colloidal crystals, the method comprising:
- filling a first monomer solution for 5 photopolymerization between planar colloidal crystals;

performing a first selective photopolymerization process between the colloidal crystals by use of a mask, to prepare firstly patterned colloidal crystals; and

second monomer solution filling а for photopolymerization between the firstly patterned colloidal 10 by crystals, followed performing at least one photopolymerization process between the firstly patterned colloidal crystals by use of an additional mask.

- 8. The method as defined in claim 7, wherein the first monomer solution or the second monomer solution for the photopolymerization comprises an acrylate monomer.
- 9. The method as defined in claim 8, wherein the 20 acrylate monomer is selected from the group consisting of hydroxypropyl methacrylate, hydroxyethyl methacrylate, methacrylate, or mixtures thereof.
- 10. The method as defined in claim 7, wherein the 25 colloidal crystals each comprise at least one selected from

the group consisting of polystyrene, polymethyl methacrylate, polyacrylate, methacrylate, polyphenyl polyalphamethylstyrene, poly1-methylcyclohexyl methacrylate, polybenzyl methacrylate, methacrylate, polycyclohexyl polychlorobenzyl methacrylate, poly1-phenylcyclohexyl 5 methacrylate, poly1-phenylethyl methacrylate, polyperfuryl poly1,2-diphenylethyl methacrylate, methacrylate, methacrylate, polydiphenylmethyl polypentabromophenyl methacrylate, polypentachlorophenyl methacrylate, copolymer 10 of methyl methacrylate and benzyl methacrylate, copolymer of styrene and acrylonitrile, copolymer of methyl methacryalte and 2,2,2-trifluoroethyl methacrylate, copolymer of methyl methacryalte and 2,2,3,3,3-pentafluoropropyl methacrylate, and 1,1,1,3,3,3copolymer οf methyl methacryalte hexafluoroisomethacrylate, copolymer of methyl methacryalte 15 and 2,2,3,3,4,4,4-heptafluorobutyl methacrylate, copolymer 2,2,2-trifluoroethyl methacrylate and 2,2,3,3,3of pentafluoropropyl methacrylate, copolymer of 2,2,2methacrylate trifluoroethyl and 1,1,1,3,3,3-20 hexafluoroisomethacrylate, copolymer of styrene and methyl copolymer of 2,2,2-trifluoroethyl methacrylate, and methacrylate and 2,2,3,3,4,4,4-heptafluorobutyl methacrylate.

11. The method as defined in claim 7, wherein the 25 colloidal crystals each comprise at least one selected from

the group consisting of SiO_2 , TiO_2 , ZnS, ZnO_2 , and Fe_3O_4 .

12. The method as defined in claim 7, wherein light for use in the polymerization is selected between ultraviolet ranges and visible ranges.